

DESCRIPTION:

The **2VH01** is a vertical Hall device (patent pending) that can be incorporated as a cell into an integrated circuit designed for 0.35µm CMOS process.

The output voltage of the 2VH01 is proportional to a magnetic field component parallel with the chip surface.

The 2VH01 cell (or a cluster of such cells) can be readily integrated into a Hall sensor circuit, such as the spinning-current circuit.

KEY FEATURES:

- Sensitive to magnetic field parallel with the chip surface
- The sensitivity vector can be parallel with the X or Y axis of the chip, or tilted to 45°
- 0.35µm bulk CMOS technology
- Small cell size
- High signal-to-noise ratio
- Interchangeable biasing and sense contacts – suitable for the spinning current circuit

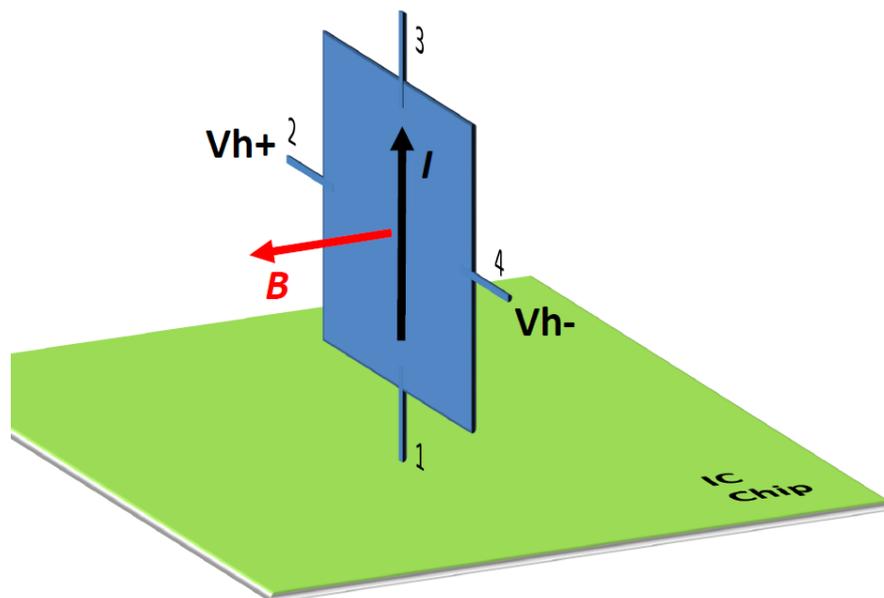


Figure 1. Illustrating position, biasing, and response of the 2VH01. The active area of the Hall device is an n-type plate-like region, which is imbedded into the p-type substrate of the chip so that the planes of the Hall device and the chip are mutually orthogonal. Notation: 1, 2, 3, 4 - the current (input) and/or sense (output, Hall voltage) terminals; I – the biasing current; B – the magnetic field induction; Vh+, Vh- – the positive and negative terminals of the Hall voltage generator, respectively.

ABSOLUTE MAXIMUM RATINGS:

Parameter	Value	Remark
Supply voltage range	-0.5V to +6V	Any terminal (1, 2, 3 or 4) to substrate
Operating temperature range	-40°C to +125°C	

CHARACTERISTICS:

Unless otherwise noted, the specifications apply for the biasing voltage V_b (between the current terminals) of 1V, with the „low“ biasing terminal connected to the substrate, at the temperature 20°C.

Parameter	Value	Remark
Sensitivity vector	Parallel with surface	<i>With respect to the chip surface</i>
Dimensions of the cell	25µm x 40µm	<i>Overall dimensions</i>
Magnetic sensitive volume	10 x 25 x 5µm ³	<i>1µm: Perpendicular to the surface</i>
Resistance R_{in}, R_{out}	1.2kΩ ±10%	<i>Between the terminals 1-2 or 3-4</i>
Offset voltage V_{Off}	±2mV (typical)	<i>at $B = 0T$</i>
Common output voltage V_C	0.45V	<i>With respect to "low" biasing terminal</i>
Magnetic sensitivity S_V	0.04V/VT ±3%	<i>Bias-voltage-related magn. sensitivity</i>
Magnetic sensitivity S_I	45V/AT ±10%	<i>Bias-current-related magn. sensitivity</i>
Noise voltage spectral density	See Figure 2	
Corner frequency of 1/f noise (f_c)	2kHz (typical)	<i>Where 1/f noise equals thermal noise</i>
NEMFsd ^{*)} at $f > 10 \times f_c$	120nT*V/√Hz / V_b	<i>V_b: biasing voltage</i>

^{*)} NEMFsd: Noise-equivalent magnetic field spectral density

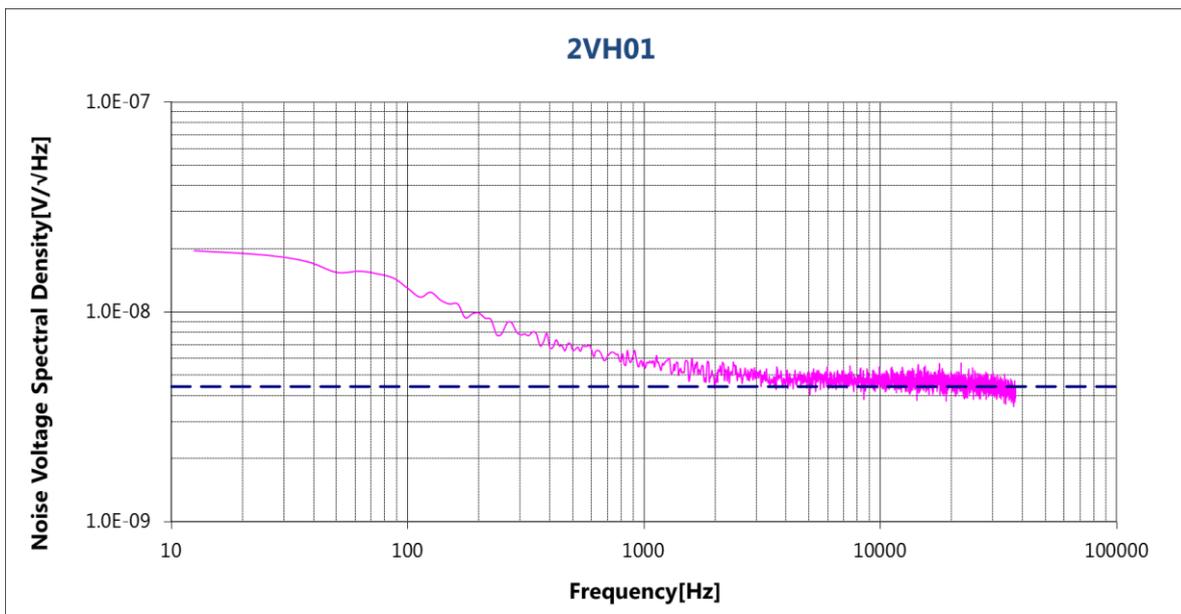


Figure 2. **Nose voltage spectral density of the 2VH01 vs. frequency. The dashed line indicates the thermal noise floor of a 1.2kΩ resistor.**

Note: A cluster of N cells 2VH01 connected in parallel will have the following characteristics:

- Resistance R_{in}, R_{out} : $R_N = R_1 / N$;
- Sensitivity $S_{VN} = S_{V1}, S_{IN} = S_{I1} / N$;
- Offset $V_{offN} = V_{off1} / \sqrt{N}$;
- Noise $V_{nN} = V_{n1} / \sqrt{N}$,

where the suffix 1 indicates a value of 2VH01, and N indicates a value of N parallel-connected 2VH01.